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APPLICATION NO.	FILING DA	ATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/698,875	10/31/2003		Bulent M. Basol	NT-286-US	2008
7:	590 08	8/02/2005		EXAMINER	
NuTool, Inc.				DOLAN, JEI	NNIFER M
Legal Departme 1655 McCandle				ART UNIT	PAPER NUMBER
Milpitas, CA	Milpitas, CA 95035			2813	
				DATE MAILED: 08/02/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	
Office Action Summany	10/698,875	BASOL ET AL.	m
Office Action Summary	Examiner	Art Unit	
	Jennifer M. Dolan	2813	
The MAILING DATE of this communication ap Period for Reply	pears on the cover sheet with the o	orrespondence addi	ress
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a rep - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statut Any reply received by the Office later than three months after the mailin earned patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply be tingly within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from e, cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this com D (35 U.S.C. § 133).	nmunication.
Status			
1) Responsive to communication(s) filed on 23 h	May 2005.		
	s action is non-final.		
3) Since this application is in condition for allowated closed in accordance with the practice under a secondary condition.			nerits is
Disposition of Claims			
4) ⊠ Claim(s) 1-32 is/are pending in the application 4a) Of the above claim(s) 5,6,9-18 and 20-32 is 5) □ Claim(s) is/are allowed. 6) ⊠ Claim(s) 1-4,7,8 and 19 is/are rejected. 7) □ Claim(s) is/are objected to. 8) □ Claim(s) are subject to restriction and/or	s/are withdrawn from consideration	on.	
Application Papers			
9)☐ The specification is objected to by the Examine	er.		
10)⊠ The drawing(s) filed on 23 May 2005 is/are: a	• • •	•	
Applicant may not request that any objection to the	• • •	• •	
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the E			
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documen 2. Certified copies of the priority documen 3. Copies of the certified copies of the priority application from the International Burea * See the attached detailed Office action for a list	ts have been received. ts have been received in Applicationity documents have been receiven to (PCT Rule 17.2(a)).	on No ed in this National S	tage
Attachment(s)	_		
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08 Paper No(s)/Mail Date 3/22/04. 	4) Interview Summary Paper No(s)/Mail Da) 5) Notice of Informal P 6) Other:	ate	152)

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DETAILED ACTION

Election/Restrictions

1. Claims 5, 6, 9-18, and 20-32 have been withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim. Election was made **without** traverse in the reply filed on 5/23/05.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 3. Claims 1-4 and 19 are rejected under 35 U.S.C. 102(b) as being anticipated by U.S. Patent No. 4,968,375 to Sato et al.

Regarding claims 1, 2, and 19, Sato discloses a method of removing a conductive material from an edge region of a workpiece/semiconductor IC device (see column 1, lines 5-15; column 2), comprising: supplying an etch solution to create an etchant bead (column 6, lines 14-18) at a contoured opening (21a) of an edge removal device (figure 2a); contacting the edge region of the workpiece with the etchant bead (column 3, lines 17-50; column 6, lines 14-30);

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and establishing relative motion between the workpiece and the edge removal device to remove the conductive material from the edge region of the workpiece (column 5, lines 15-35; column 6, lines 5-14), where the etchant bead is maintained at the opening of the removal device (column6, lines 14-17).

Regarding claims 3 and 4, Sato discloses that the edge removal device comprises a cavity (21a) having the opening, such that the edge of the workpiece is inserted into the cavity and the etch solution contacts the top, bottom, and side of the workpiece (figures 2a, 2b; column 3, lines 30-50).

4. Claims 1-4 and 19 are rejected under 35 U.S.C. 102(e) as being anticipated by U.S. Patent No. 6,523,553 to Redeker et al.

Regarding claims 1, 2, and 19, Redeker discloses a method of removing a conductive material (column 1, lines 50-52) from an edge region of a workpiece/semiconductor IC (column 2, lines 5-45; 60-67) comprising the steps: supplying an etch solution (column 5, lines 5-25) to create an etchant beat at a contoured opening (31) of an edge removal device (figure 2); contacting the edge region of the workpiece with the etchant bead (column 5, lines 34-46); and establishing relative motion between the workpiece and the edge removal device to remove the conductive material from the edge of the workpiece (column 5, lines 36-42), where the edge bead is maintained at the opening (column 5, lines 9-14; etchant supply and outlet lines maintain the edge bead).

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Regarding claims 2 and 3, Redeker discloses a cavity (31), where the edge of the workpiece is inserted into the cavity (figure 2), and where the etch solution contacts the top, bottom, and side of the workpiece (figure 2; column 5).

Claim Rejections - 35 USC § 103

- 5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 6. Claims 7 and 8 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sato et al. in view of U.S. Patent No. 6,550,091 to Radman et al.

Sato fails to disclose that the cavity includes a spongy material, where the edge region of the workpiece is contacted with the spongy material.

Radman discloses a method for scrubbing the edge portions of a wafer, wherein the cavity includes etchant solution and a spongy material (230) that contacts the workpiece (see column 5, lines 15-47; figures 3b; 4; 5).

It would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the method of Sato, such that a spongy material contacting the workpiece edges is included, as suggested by Radman. The rationale is as follows: A person having ordinary skill in the art would have been motivated to include a spongy material, because Radman teaches that the combination of applying an etching solution and scrubbing the wafer

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with a pliable pad material will aid in removing undesired metal deposits and will more efficiently clean the wafer (see Radman, column 3, lines 1-10; column 5, lines 15-45; column 6, lines 22-27).

Conclusion

- 7. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.
 - a. U.S. Patent No. 6,063,232 to Terasawa et al. teaches polishing a wafer by applying a foam scrubbing member and a bead of etchant solution in a cavity.
 - b. U.S. Patent No. 5,868,857 to Moinpour et al. discloses using pads and etchantsupply nozzles for cleaning the periphery of a wafer.
 - c. U.S. Patent No. 5,608,943 to Konishi et al. discloses an apparatus for cleaning the bottom outer periphery of a semiconductor wafer.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Jennifer M. Dolan whose telephone number is (571) 272-1690. The examiner can normally be reached on Monday-Friday 8:30am-5:00pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Carl W. Whitehead, Jr. can be reached on (571) 272-1702. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Jennifer M. Dolan Examiner Art Unit 2813

jmd

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